

09/936289

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

ATTY.'S DOCKET: SATO=22

In re Application of:
Taizo SATO et al.

) Art Unit:

) Examiner:

I.A. No.: PCT/JP00/01402

) Washington, D.C.

Filed: March 8, 2000

) September 12, 2001

For: MATERIAL FOR SHADOW MASK..

PRELIMINARY AMENDMENT

Honorable Commissioner for Patents and Trademarks
Washington, D.C. 20231

Sir:

Contemporaneous with the filing of this case and prior to
calculation of the filing fee, kindly amend as follows:

IN THE SPECIFICATION

After the title please insert the following paragraph:

REFERENCE TO RELATED APPLICATIONS

--The present application is the national stage under 35
U.S.C. §371 of international application PCT/JP00/01402, filed March
8, 2000 which designated the United States, and which application
was not published in the English language.--

IN THE CLAIMS

✓
Please amend claim 5 as follows:

5. (Amended) Shadow mask made of the material as claimed in
claim 1.